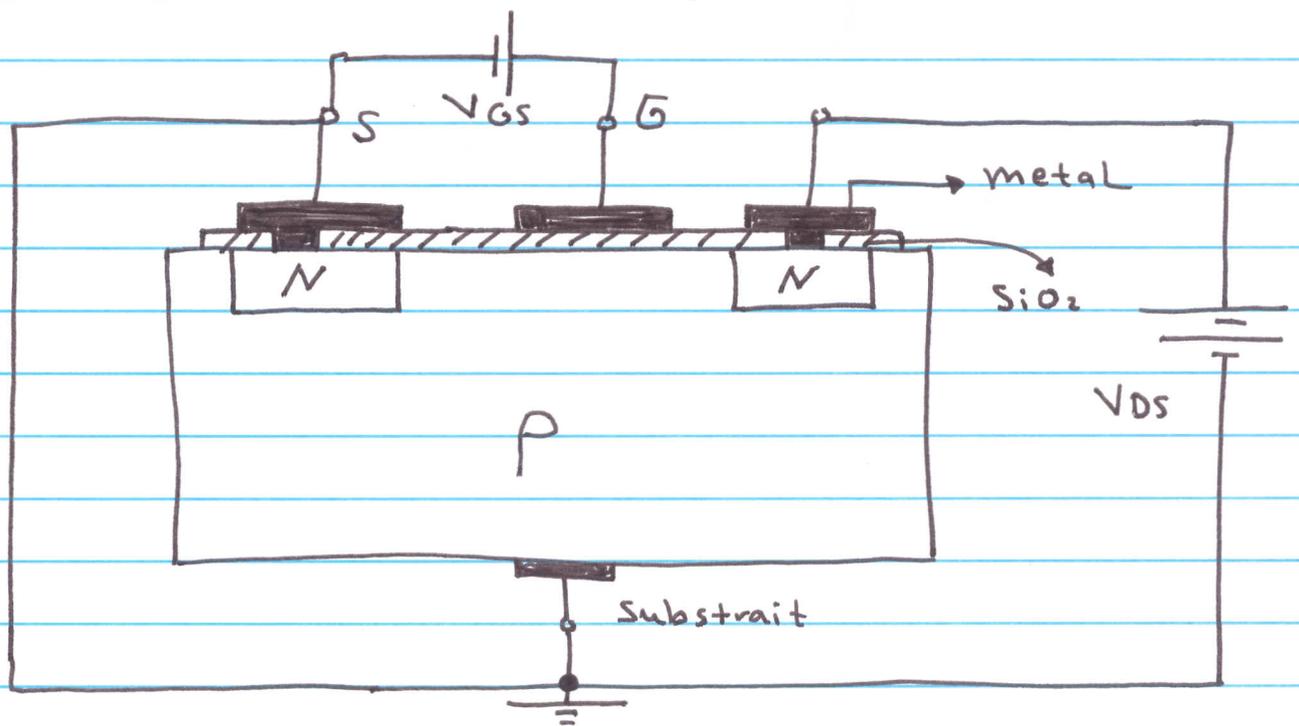


Enhancement type MOSFET

Construction of n-channel EMOSFET :



Operation, characteristics and parameters of n-channel EMOSFET

- On the application of V_{DS} and keeping $V_{GS} = 0$, practically zero current flows
- If we increase V_{GS} in the positive direction, the concentration of electrons near the SiO_2 surface increases.
- At a particular value of V_{GS} there is

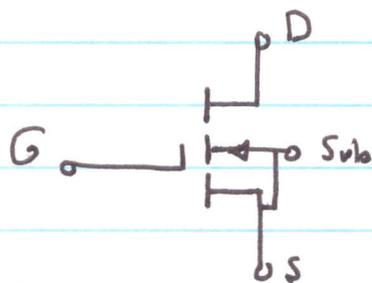
a measurable current flow between drain and

source ; I_{DS}

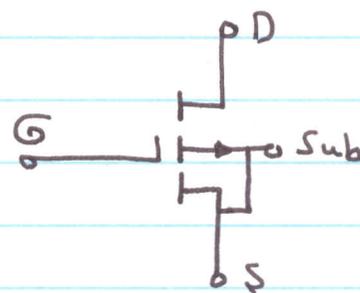
This value of V_{GS} is called Threshold voltage denoted by V_T .

- A positive V_{GS} above V_T induce a channel and hence the drain current (I_{DS}) by creating a thin layer of negative charges (electrons) in the substrate region adjacent to the SiO_2 Layer.

- The conductivity of the channel is enhanced by increasing V_{GS} and thus pulling more electrons into the channel.

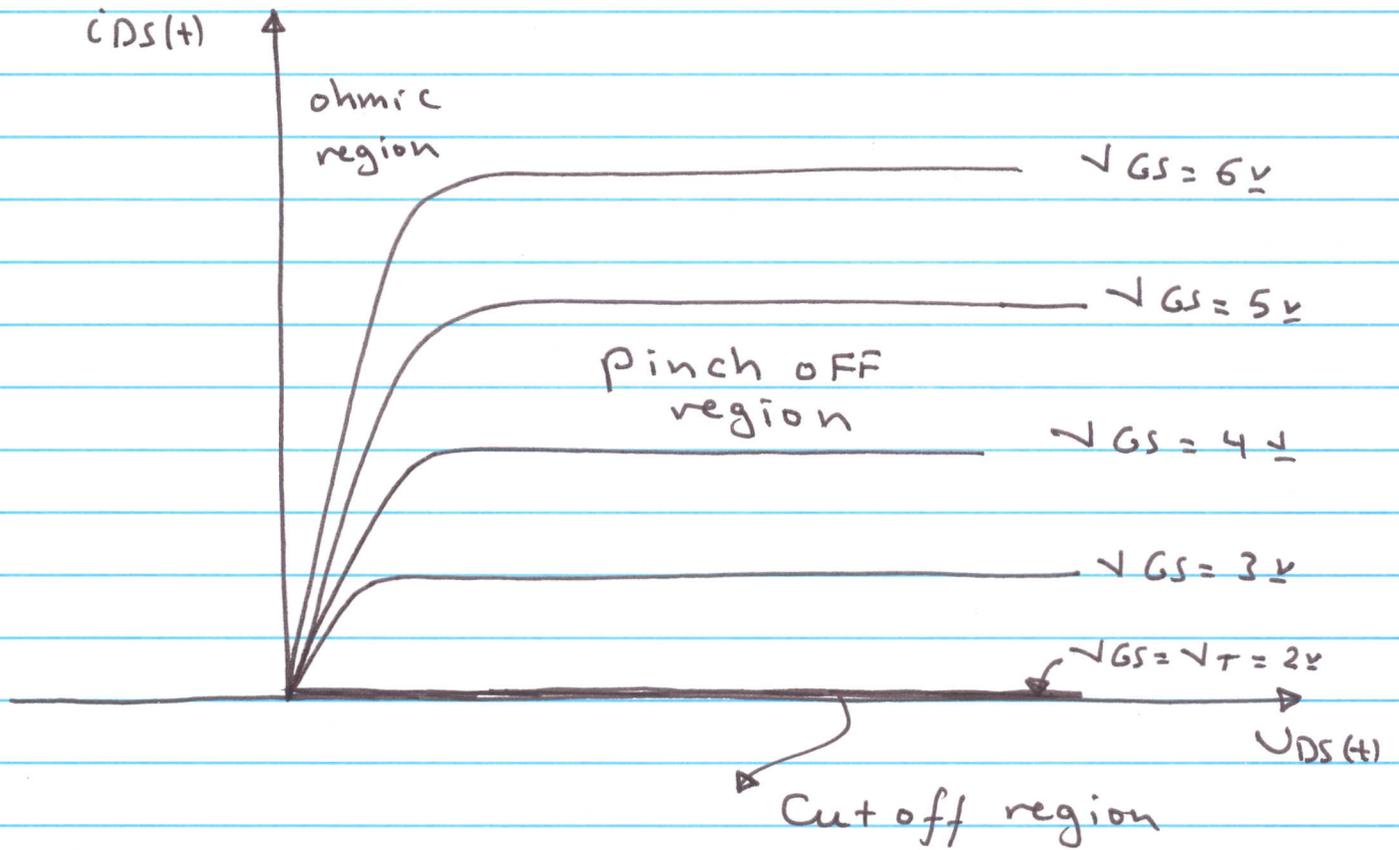


n-channel
EMOSFET

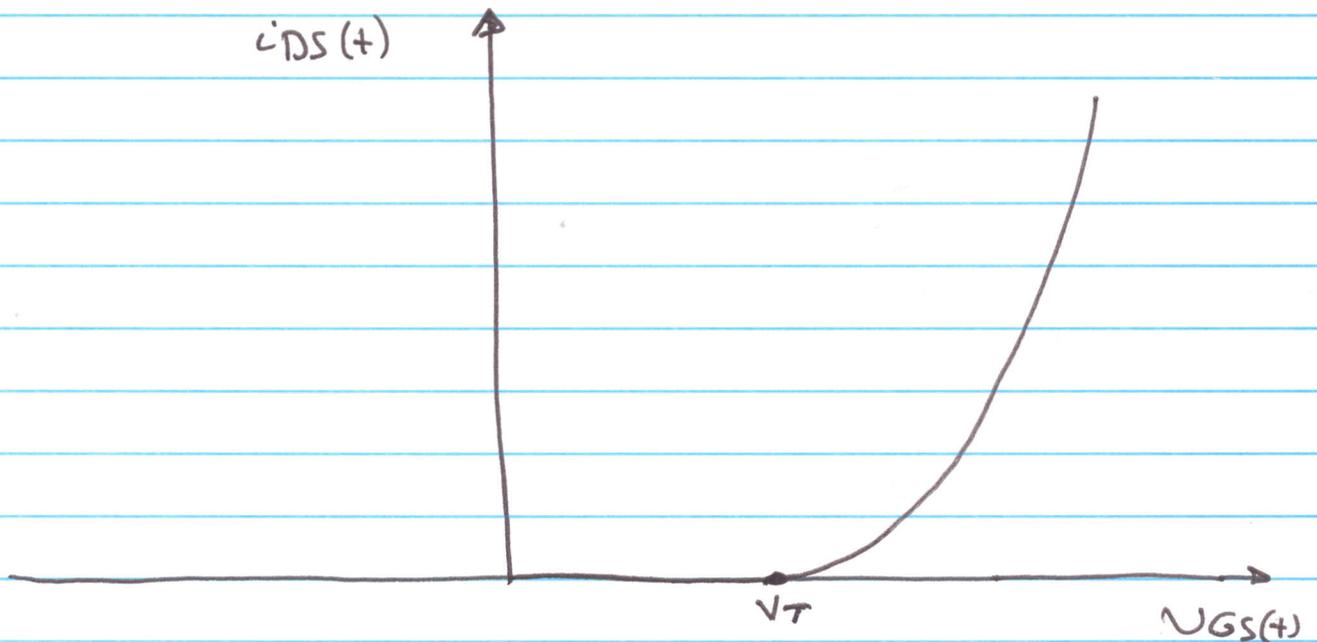


p-channel
EMOSFET

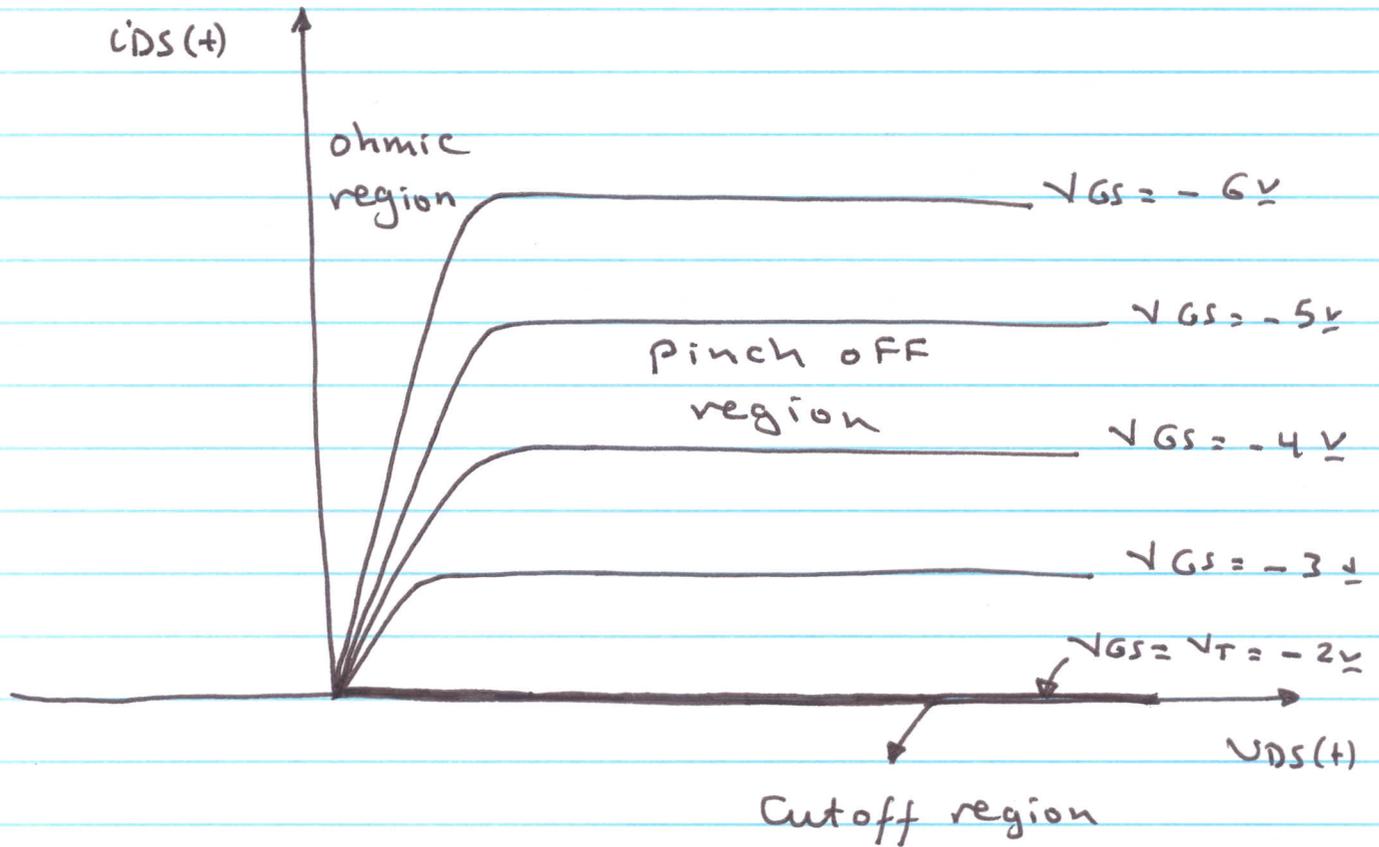
Drain characteristics for an n-channel EPMOSFET



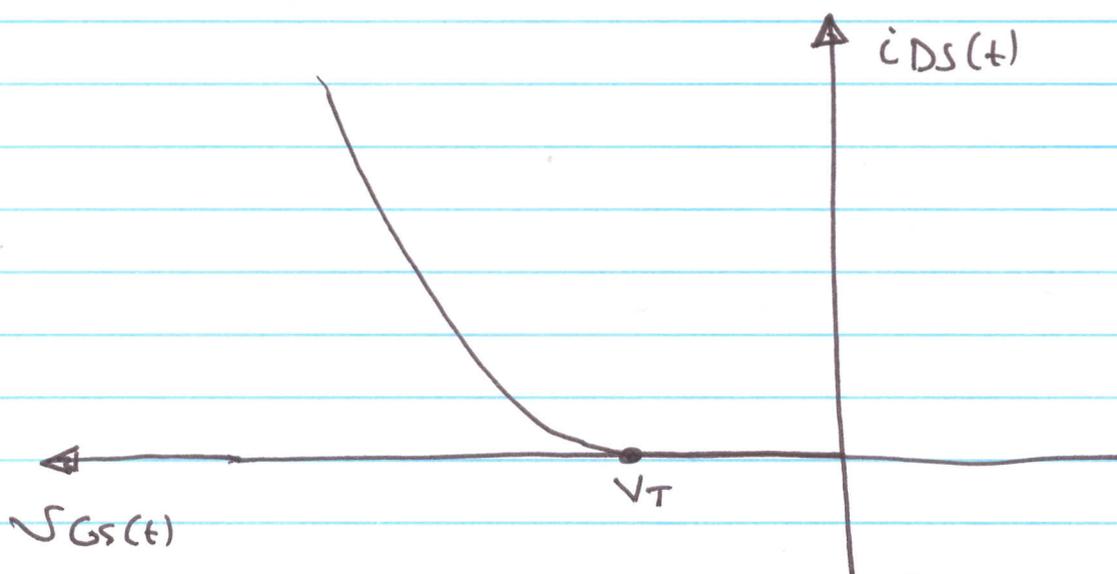
Transfer characteristic for an n-channel EPMOSFET



Drain characteristics of p-channel E-MOSFET



Transfer characteristic of p-channel E-MOSFET



In the pinch off region

$$i_{DS}(t) = K_n \left(V_{GS}(t) - V_T \right)^2$$

$$K_n = \frac{1}{2} \bar{K}_n \frac{W}{L}$$

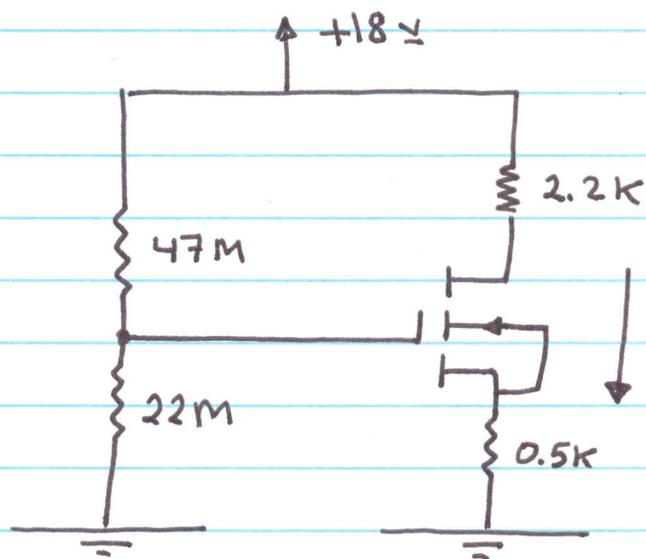
$$\bar{K}_n = \mu_n C_{ox}$$

$$|V_{DS}| > |V_{GS} - V_T|$$

$$V_{GS} > V_T \quad \text{n-channel}$$

$$V_{GS} < V_T \quad \text{p-channel}$$

Example



$$K_n = 0.25 \times 10^{-3} \text{ A/V}^2$$

$$V_T = 2 \text{ V}$$

$$I_{D_S} = K_n (\sqrt{V_{GS}} - V_T)^2 \quad \text{--- (1)}$$

$$\sqrt{V_{GS}} = \sqrt{V_G} - \sqrt{V_S}$$

$$\sqrt{V_G} = \frac{22 \text{ M}}{22 \text{ M} + 47 \text{ M}} \cdot (18) = 5.74 \text{ V}$$

$$\sqrt{V_S} = (0.5 \text{ K}) I_{D_S}$$

$$\sqrt{V_{GS}} = 5.74 - 0.5 \text{ K} I_{D_S} \quad \text{--- (2)}$$

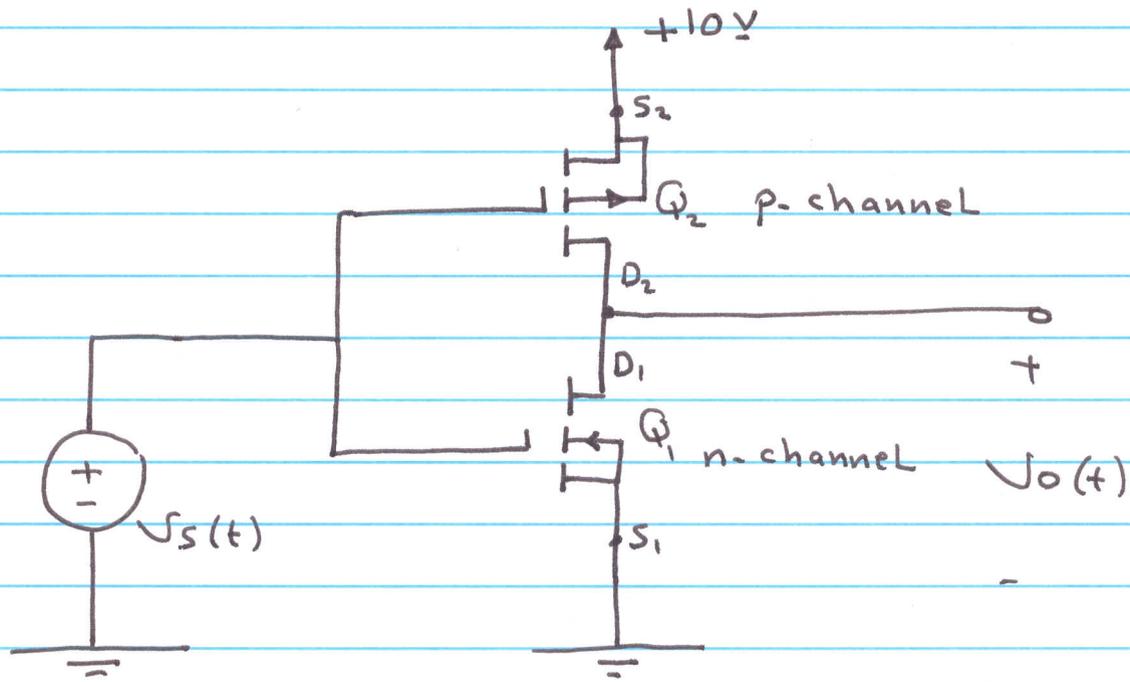
Solving for $\sqrt{V_{GS}}$;

$$\sqrt{V_{GS}} = \begin{cases} 4.78 \text{ V} & \checkmark \\ -8.78 & \times \end{cases}$$

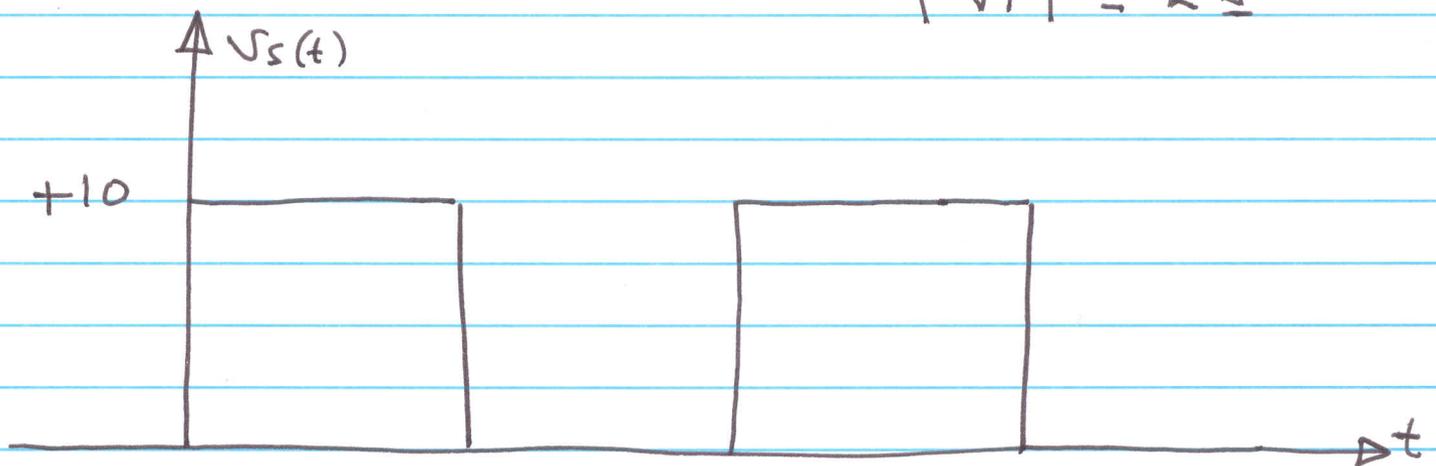
$$\therefore I_{D_S} = 1.92 \text{ mA}$$

$$V_{D_S} = 12.82 > |\sqrt{V_{GS}} - V_T|$$

A Complementary MOS (CMOS) Inverter



$$|V_T| = 2 \text{ V}$$



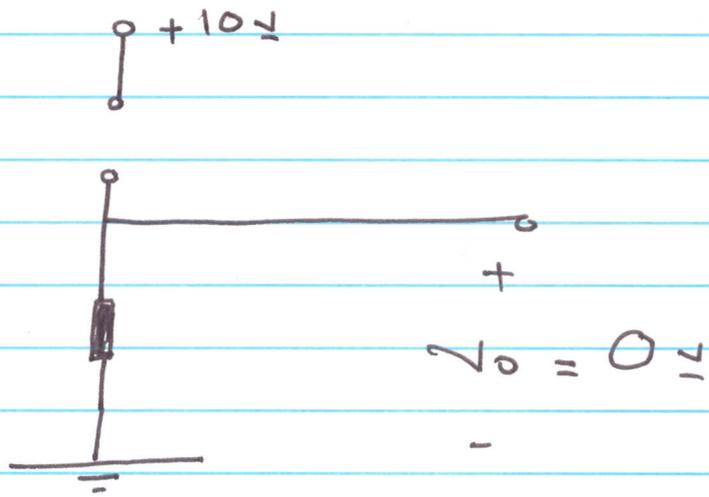
1) Let $v_s(t) = +10 \text{ V}$

$$V_{GS1} = V_{G1} - V_{S1} = 10 - 0 = 10 \text{ V} > V_{T1}$$

$\therefore Q_1$ is on, replaced with short

$$V_{GS2} = V_{G2} - V_{S2} = 10 - 10 = 0 < V_{T2}$$

$\therefore Q_2$ is OFF, replaced with open circuit



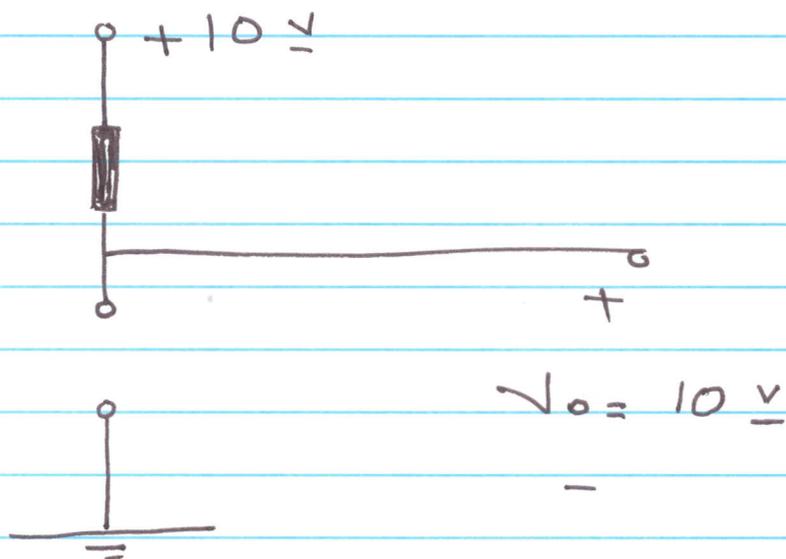
2) Let $v_s(t) = 0$

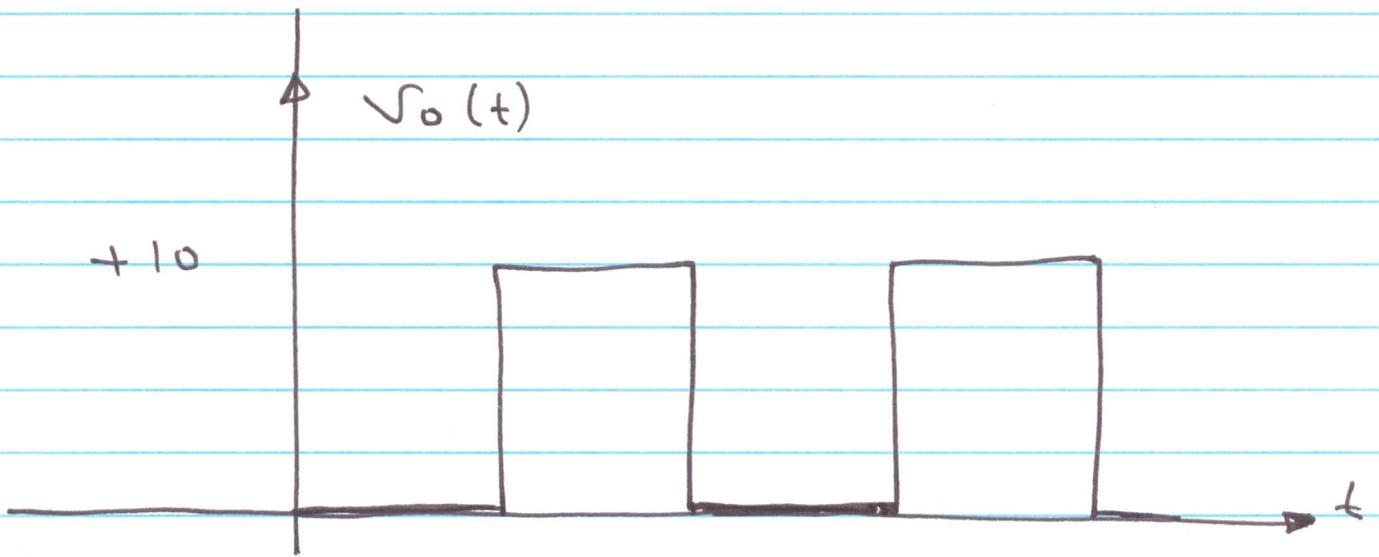
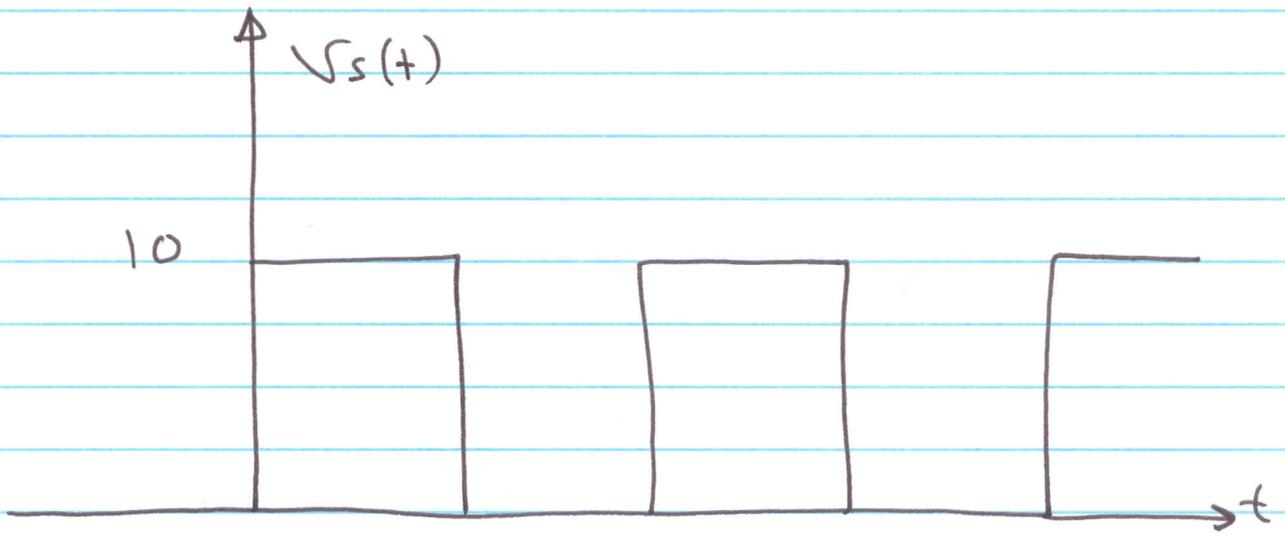
$$V_{GS1} = V_{G1} - V_{S1} = 0 < V_{T1}$$

$\therefore Q_1$ is OFF; replaced with open circuit

$$V_{GS2} = V_{G2} - V_{S2} = 0 - 10 = -10 < V_{T2}$$

$\therefore Q_2$ is on; replaced with short circuit





Inverter \equiv Not gate